Tool ID: 307 Tool Location: 110

Equipment Information Sheet

CHA Mark 50 E-beam Evaporator

Manager: Aaron Windsor 607-254-4831 Backup: Christopher Alpha 607-254-4913

Calls to staff phones will be automatically forwarded to their cell phones during accessible hours. At other times

leave a message or send them an email.

SAFETY

- Wear the provided UV safety glasses when looking into the chamber when the E-gun is on.
- Be careful lowering and raising the chamber door.

USAGE RESTRICTIONS

• No Buddy Required.

SCHEDULING/SIGN-UP RESTRICTIONS

Minimum Tool Time: 60 minutes

- No more than four hour reservation.
- If more time is needed, please consult the tool manager

MATERIALS COMPATIBILITY CATEGORY

| Tool Category 5: Class A and B Metals and Compounds | |
|---|---|
| Allowed | Not Allowed |
| Tool category 1/1E, 2, 3, and 4 materials | |
| Silicon Based Substrates and Films | |
| III/V compound Semiconductors | |
| Glass Substrates | |
| PECVD and ALD Films | |
| Cured organics and baked Photoresist | |
| CNF Class A, B, and Refractory metals | |
| Exposed Gold, Silver, Copper | |
| Alkali and Alkaline Compounds | |
| Organic/Biology Molecules prepared- w/salt buffers | |
| High Vapor Pressure Materials (Mg, Ca, Zn)* | * Some tool restrictions on high vapor pressure materials may apply |
| Soft organic materials | |

High Vapor Pressure Metals and Compounds are materials that have a vapor pressure above 1e-6 Torr at 400 C.

Additional Material Restrictions and Exceptions

- No High vapor pressure materials (Pb, Ca, Zn, Sn, etc.) on substrates or sources in the evaporator.
- Only evaporate approved materials. Do Not evaporate sources materials not on the data sheet.
- No oxide evaporation will be done in this tool.

Last Updated: 09/09/2019